

SHEET 1 OF 1

INFORMATION DISCLOSURE STATEMENT PTO-1449		ATTY. DOCKET NO. 26822-0006		SERIAL NO. 09/784,972			
		APPLICANT Chan-Park, M. et al.				<i>RECEIVED JUN 26 2003 TC 1700</i>	
		FILING DATE 02/15/01		GROUP: 1756			
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
DVP	3,229,607	1/18/66	Battaglia, G.J.	95	75		
DVD	5,877,848	3/2/99	Gillette et al.	355	85		
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
DVD	60205452	10/17/85	Japan (abstract)	G03F	7/20	<input type="checkbox"/>	<input type="checkbox"/>
DVD	2000035677	02/02/00	Japan (abstract)	G03F	7/23	<input type="checkbox"/>	<input type="checkbox"/>
DVD	2000075497	03/14/00	Japan (abstract)	G03F	7/24	<input type="checkbox"/>	<input type="checkbox"/>
DVD	2001042118	02/16/01	Japan (abstract)	G02B	5/20	<input type="checkbox"/>	<input type="checkbox"/>
DVD	WO 00/60410	10/12/00	PCT	G02F	1/167		
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER <i>David Michael Davis</i>	DATE CONSIDERED <i>11/20/2003</i>						

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

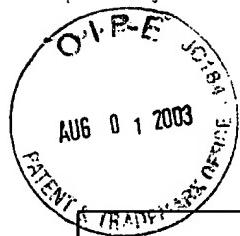


Form PTO-1449 INFORMATION DISCLOSURE STATEMENT				Attorney's Docket No. 26822-0006	Application Serial No. 09/784,972		
				Applicant(s)	Mary Chan-Park, et al.		
				Filing Date: February 15, 2001	Group Art Unit: 1756		
U.S. PATENT DOCUMENTS							
Examiner Initials	Ref. No.	Date	Patent No.	Name	Class	Subclass	Filing Date
ND	1. *	10/12/71	3,612,758	Evans, et al.	178	5.4R	REC
ND	2. *	09/5/72	3,689,346	Rowland	156	245	REC
ND	3. *	09/23/75	3,908,052	Sanders	428	1	AUG 05
ND	4. *	12/23/75	3,928,671	Robusto, et al.	427	88	REC
ND	5. *	05/03/88	4,741,988	Van der Zande, et al.	430	312	REC
ND	6. *	12/28/93	5,274,481	Kim	359	51	REC
ND	7. *	01/04/94	5,276,438	DiSanto, et al.	345	107	REC
ND	8. *	01/18/94	5,279,511	DiSanto, et al.	445	24	REC
ND	9. *	12/31/96	5,589,100	Grasso, et al.	252	299.01	REC
ND	10. *	12/16/97	5,699,097	Takayama, et al.	347	171	REC
ND	11. *	04/14/98	5,739,889	Yamada, et al.	349	156	REC
ND	12. *	11/10/98	5,835,174	Clikeman, et al.	349	86	REC
ND	13. *	08/24/99	5,942,154	Kim, et al.	252	299.01	REC
ND	14. *	11/02/99	5,976,405	Clikeman, et al.	252	299.01	REC
ND	15. *	03/14/00	6,037,058	Clikeman, et al.	428	402.2	REC
ND	16. *	05/16/00	6,064,508	Forgette, et al.	359	267	REC
ND	17. *	05/23/00	6,067,185	Albert, et al.	359	296	REC
ND	18. *	09/05/00	6,113,810	Hou, et al.	252	572	REC
ND	19. *	09/19/00	6,120,588	Jacobson	106	31.16	REC
ND	20. *	09/19/00	6,120,839	Comiskey et al.	427	213.3	REC
ND	21. *	09/19/00	6,120,946	Johnson, et al.	430	7	REC
ND	22. *	12/26/00	6,166,797	Bruzzone, et al.	349	155	REC
ND	23. *	01/09/01	6,172,798	Albert, et al.	359	296	REC
ND	24. *	02/06/01	6,184,856	Gordon, et al.	345	107	REC
ND	25. *	05/29/01	6,239,896	Ikeda	359	240	REC
ND	26. *	11/06/01	6,312,304	Duthaler, et al.	445	24	REC
ND	27. *	12/04/01	6,327,072	Comiskey, et al.	259	296	REC
ND	28. *	01/08/02	6,337,761	Rogers, et al.	359	296	REC
ND	29. *	05/21/02	6,392,785	Albert, et al.	359	296	REC
ND	30. *	05/21/02	6,392,786	Albert	359	296	REC
ND	31. *	06/04/02	6,400,430	Nakao, et al.	349	89	REC
ND	32. *	03/24/98	5,731,860	Harada et al.	349	158	REC
ND	33. *	04/20/99	5,895,541	Kobayashi et al	156	240	REC
ND	34. *	11/16/99	5,985,084	Summersgill et al.	156	273.7	REC
ND	35. *	01/02/90	4,891,245	Micale	427	213.3	REC
ND	36. *	02/25/03	6,525,865	Katase, et al	359	296	REC
ND	37. *	12/01/98	5,843,333	Hakemi, Hussan	252	299.5	REC
ND	38. *	02/20/01	6,191,250	Aida et al.	528	196	REC
ND	39. *	11/30/99	5,995,190	Nagae et al.	349	156	REC
ND	40. *	09/24/99	5,956,112	Fujimori et al.	349	156	REC



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U.S. PATENT DOCUMENTS							
Examiner Initials	Ref. No.	Date	Patent No.	Name	Class	Subclass	Filing Date
MD	41. *	09/12/95	5,450,220	Onishi et al.	349	89	
MD	42.	03/14/95	5,398,041	Hyatt	345	88	
MD	43.	07/11/95	5,432,526	Hyatt	345	87	
MD	44. *	06/06/72	3,668,106	Ota, Isao	358	305	
MD	45. *	05/27/75	3,885,964	Nacci, George Raymond	430	326	
MD	46. *	05/03/88	4,741,604	Kornfeld, Cary D.	359	296	
MD	47. *	04/06/93	5,200,120	Sakai, Naomi	264	1.33	
MD	48. *	09/05/00	6,113,836	Sakai, et al.	347	171	
MD	49. *	06/04/02	6,400,492	Morita et al.	264	400	
MD	50. *	01/28/03	6,512,626	Schmidt	359	296	
MD	51. *	02/04/03	6,514,328	Katoh, et al.	106	31.28	
MD	52. W	09/19/02	Pub. No. 2002-0131152 (USSN 10/087,527)	Liang et al.			
MD	53. W	02/27/03	Pub. No. 2003-0039022 (USSN 10/237,522)	Liang et al.			
MD	54. W	06/20/02	Pub. No. 2002-75556 (USSN 09/942,532)	Liang et al.	Same as Ref. No. 79		
MD	55. W	03/20/03	Pub. No. 2003-0053190 (USSN 10/092,936)	Liang et al.			
MD	56. W	01/09/03	Pub. No. 2003-0007238 (USSN 10/179,997)	Liang et al.			
MD	57. *	09/02	Pub. No. 2002-0126249 (USSN 09/759,212)	Liang et al.	Same as Ref. No. 76		
MD	58. T	03/03/00	USSN 09/518,488	Liang et al.	Same as Ref. No. 75		
MD	59. T,W	03/14/03	USSN 10/388,890	Liang et al.			
MD	60. T,W	01/24/03	USSN 10/351,460	Liang et al.			
MD	61. T,W	02/21/03	USSN 10/372,027	Liang et al.			
MD	62. T,W	05/23/03	USSN 10/444,760	Liang et al.			
MD	63. T	06/28/00	USSN 09/606,654	Liang, et al.	Same as Ref. No. 77		



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FOREIGN PATENT DOCUMENTS							
Examiner Initials	Ref. No.	Date	Patent No.	Country	Class	Subclass	Translation YES NO
WD	64. *	6/29/82	57-104116	Japan (Abstract)	G02F	1/17	
WD	65. *	09/28/84	59-171930	Japan (Abstract)	G02F	1/19	
WD	66. *	03/30/89	64-86116	Japan (Abstract)	G02F	1/19	
WD	67. *	09/06/90	2-223934	Japan (Abstract)	G02F	1/167	
WD	68. *	11/21/90	2-284125	Japan (Abstract)	G02F	1/167	
WD	69. *	09/02/94	6-242423	Japan (Abstract)	G02F	1/1333	
WD	70. *	12/17/98	WO 98/57226	PCT	G02F	1/136	
WD	71. *	11/04/99	WO 99/56171	PCT	G02F	1/167	
WD	72. *	02/18/99	WO 99/08151	PCT	G02F	1/1339	
WD	73. *	01/20/00	WO 00/03291	PCT	G02F	1/167	
KLP	74. *	06/22/00	WO 00/36649	PCT	H01L	23/532	
WD	75. W	09/13/01	WO 01/67170	PCT	G02F	1/167	
WD	76. X	07/18/02	WO 02/56097	PCT	G02F		
WD	77. Z	08/22/02	WO 02/65215	PCT	G03F		
DCP	78. Y	01/03/02	WO 02/01281	PCT	G02F	1/00	
WD	79. W	03/06/03	WO 03/19280	PCT	G02F	1/167	
WD	80. *	04/05/00	0 990 942 A1	Europe	G02F	1/1339	
KLP	81. *	01/03/01	1 065 553 A1	Europe	G02F	1/1333	
WD	82. *	04/04/01	1 089 118 A2	Europe	G02F	1/167	
OTHER DOCUMENTS (including author, title, date, pertinent pages, etc.)							
Examiner Initials	Ref. No.	Title					
WD	83. *	Comiskey et al., "An electrophoretic ink for all-printed reflective electronic displays", Letters to Nature, May, 1998.					
WD	84. *	Harbour, J.R., et al., "Subdivided Electrophoretic Display" <i>Xerox Disclosure Journal</i> , Vol. 4, No. 6, pp. 705, November 1979.					
WD	85. *	Harvey, T.G., "Replication techniques for micro-optics", <i>SPIE</i> Vol. 3099, pp. 76-82, 1997.					
WD	86. *	Lewis, J. "Electrophoretic Displays", Allen Clark Research Centre , pp. 223-240.					
WD	87. *	Nakamura, et al., "Development of Electrophoretic Display Using Microcapsulated Suspension" <i>SID Digest</i> , pp. 1014-1017, 1998.					
WD	88. *	Ota, et al., "Electrophoretic Image Display (EPID) Panel", <i>Proceedings of the IEEE</i> , Vol. 501, No. 7, July 1973.					
WD	89. *	Drzaic, P., <i>Liquid Crystal Dispersions</i> , Chp. 1, World Scientific, 1995.					
WD	90. *	Slafer, W.D., et al., "Continuous Manufacturing of Thin Cover Sheet Optical Media", <i>SPIE Proc.</i> Vol. 1663, pp. 324-335, 1992.					
EXAMINER				DATE CONSIDERED 11/20/2003			

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